

NANORESIST

Engineering the Refractive Index for Photonic Structures

Ethan J. Kuhn REV

PI: Dr. Jiangdong Deng

Mentor: Guixiong Zhong

Department: 3D Nanotechnology



HARVARD

John A. Paulson
School of Engineering
and Applied Sciences



Center for
Nanoscale
Systems

Harvard University
FAS 3-860B



National Nanotechnology
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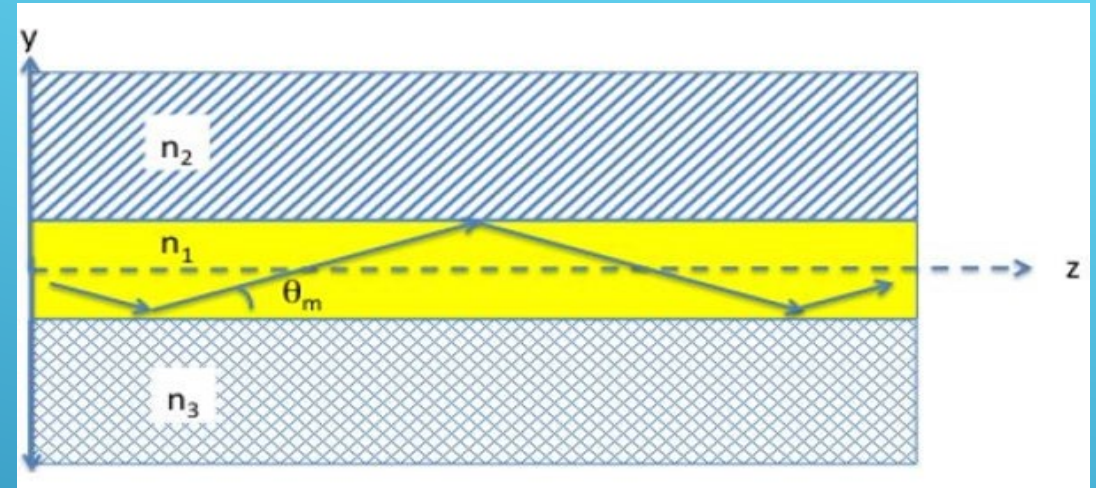


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Why is the Index Important?

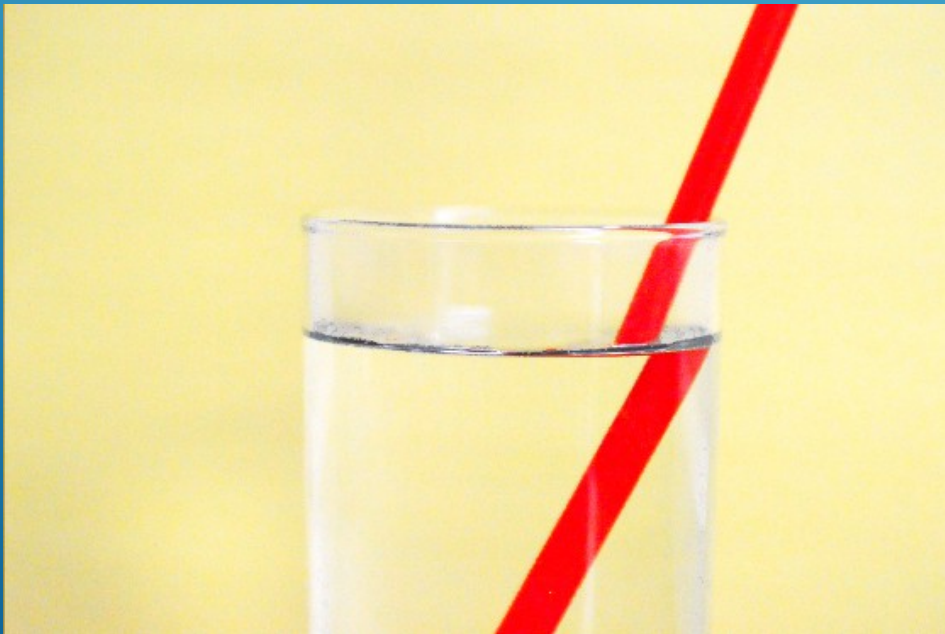
The refractive index measures how light travels through an object

$$n = \frac{c}{v},$$



Illustrated demonstration of the refractive index within a waveguide

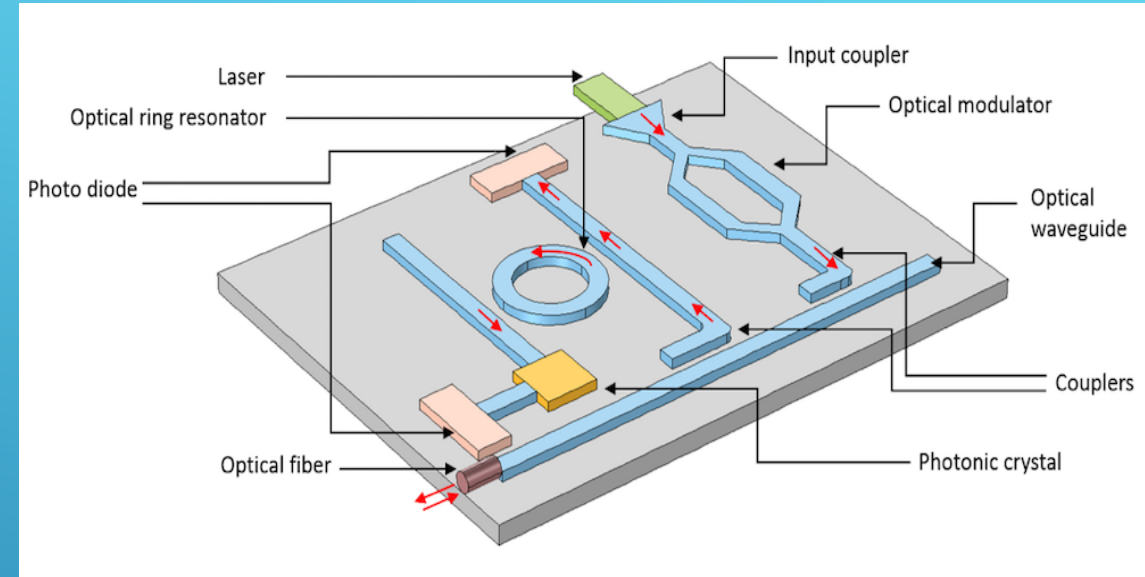
Understanding the index is fundamental to the research and development of photonics



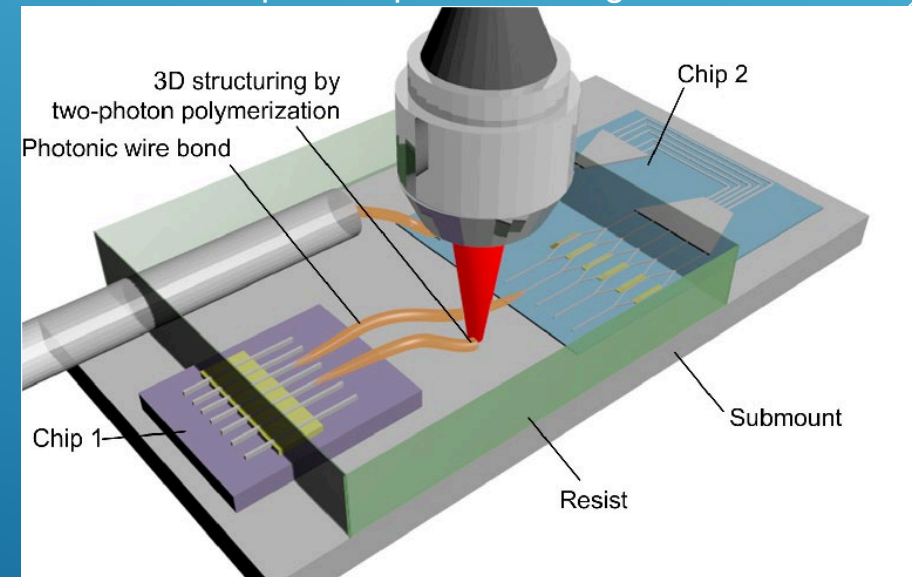
the index of the water refracts the image of the straw

Photonic Integrated Circuits/ Photonic Wire Bonding

- Photonic devices are instruments that transfer information using light in a manner similar to electronics
- Photonic integrated circuits (PIC) are devices that combine multiple components
- Optical connections link individual components together
- Nanoscribe 3D lithography for fabricating Photonic Wire Bonding (PWB)

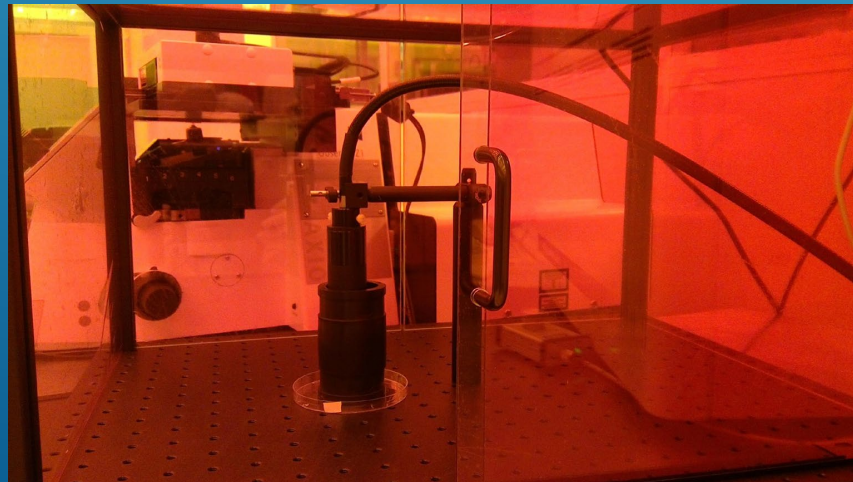
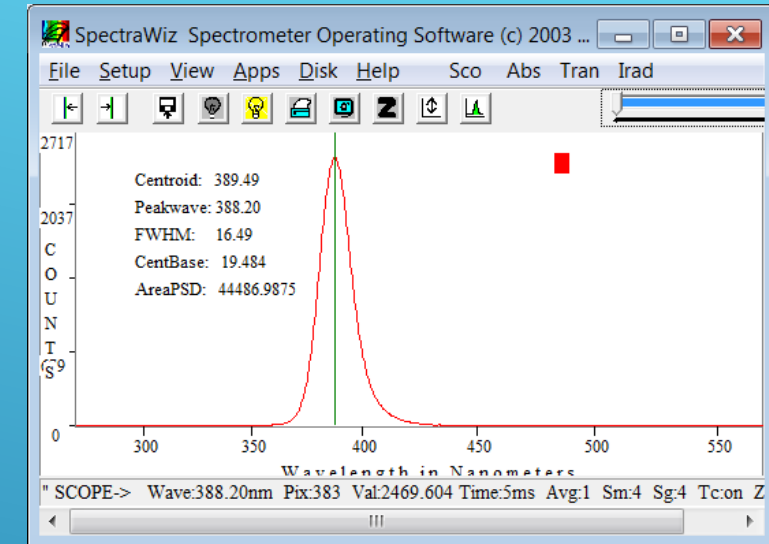
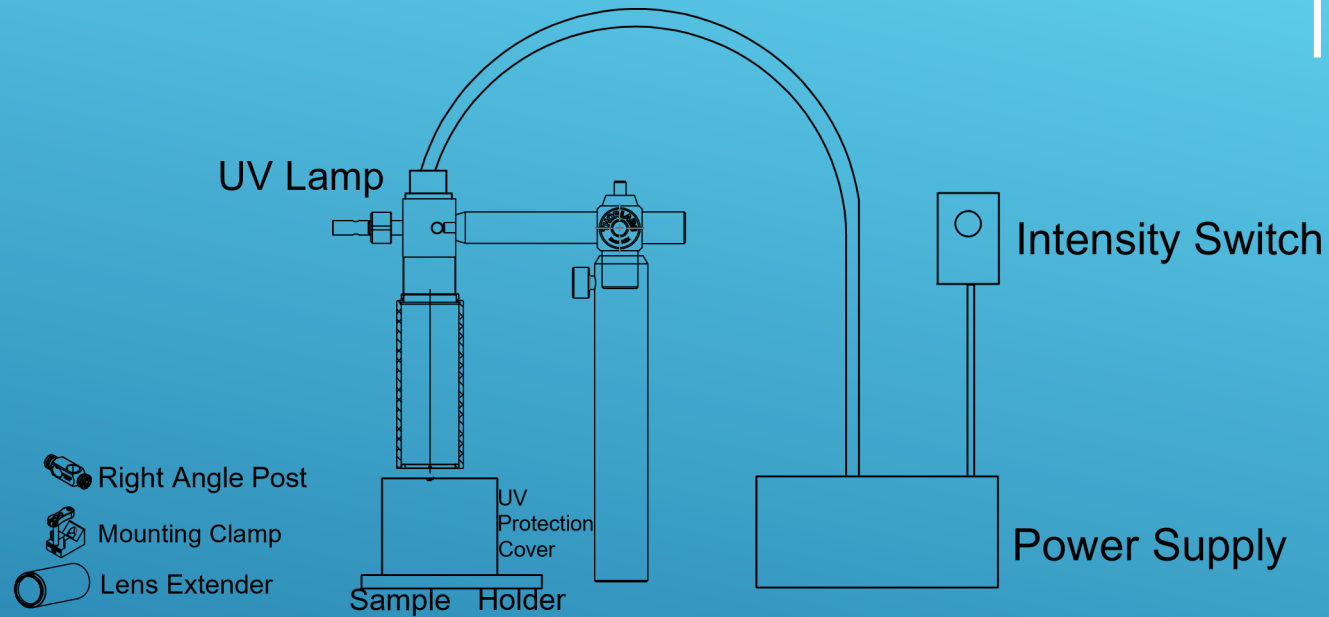


An example of a photonic integrated circuit



A photonic wire bonding two structures together

The UV Exposure Setup



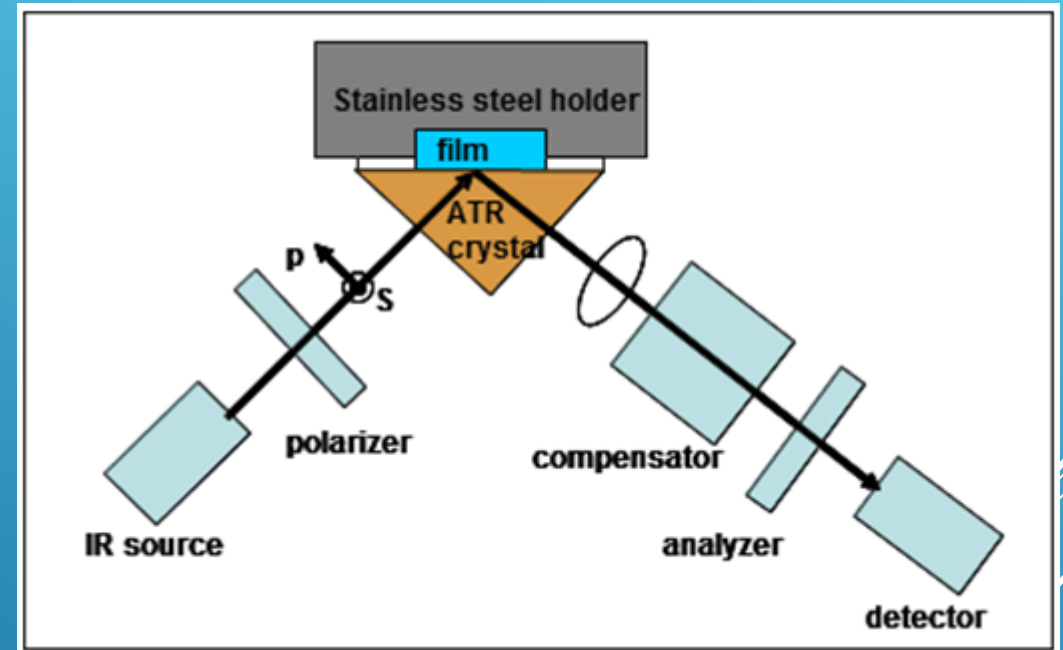
Dosage = intensity of UV light x time



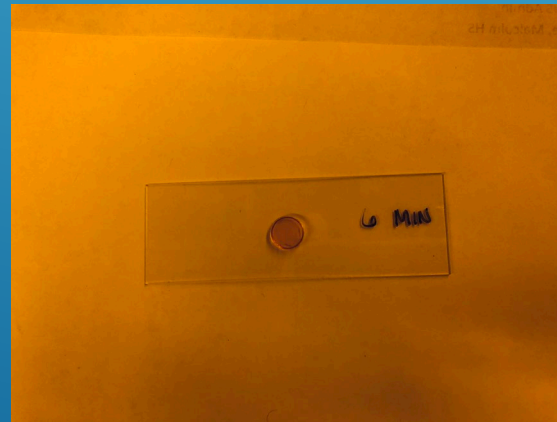
The measurement device



J.A. Woollam VASE
spectroscopic ellipsometer
measures dielectric
properties of thin films



The Block Approach



Bond PDMS to glass slide



Carve cells into PDMS



Pour IP-DIP in PDMS cells

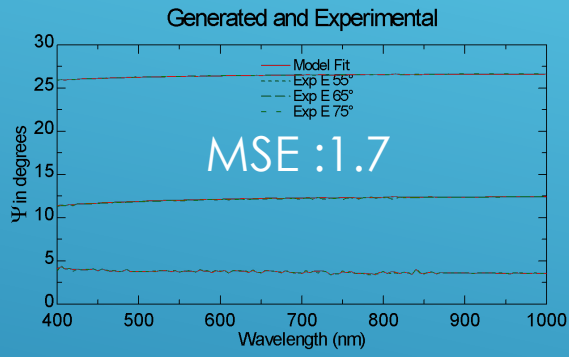


Expose sample (dosage = intensity x time exposed)

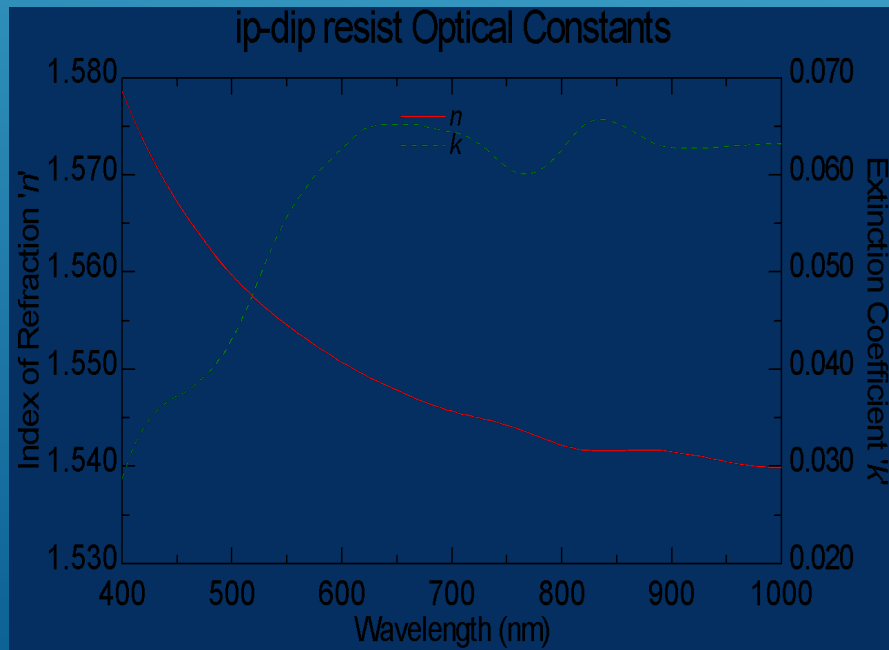


Run scan of sample on VASE

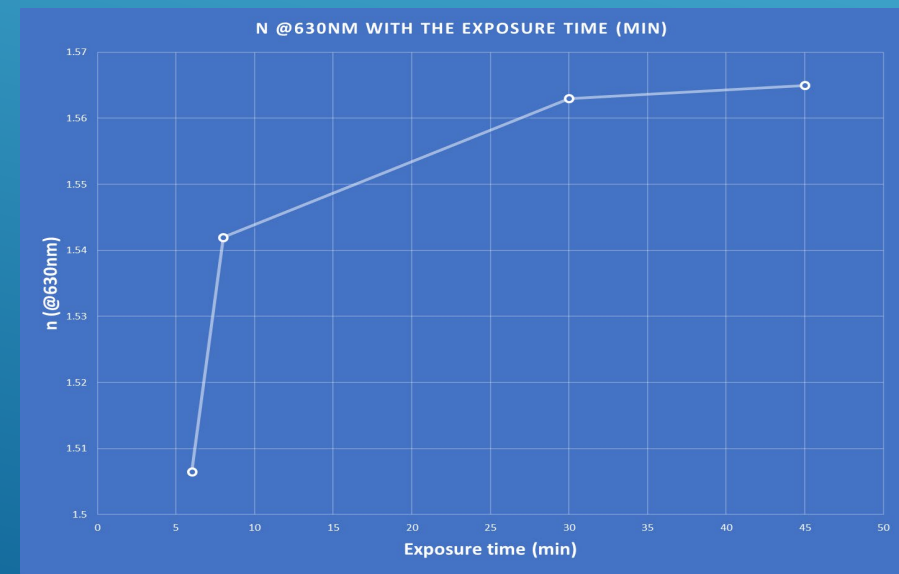
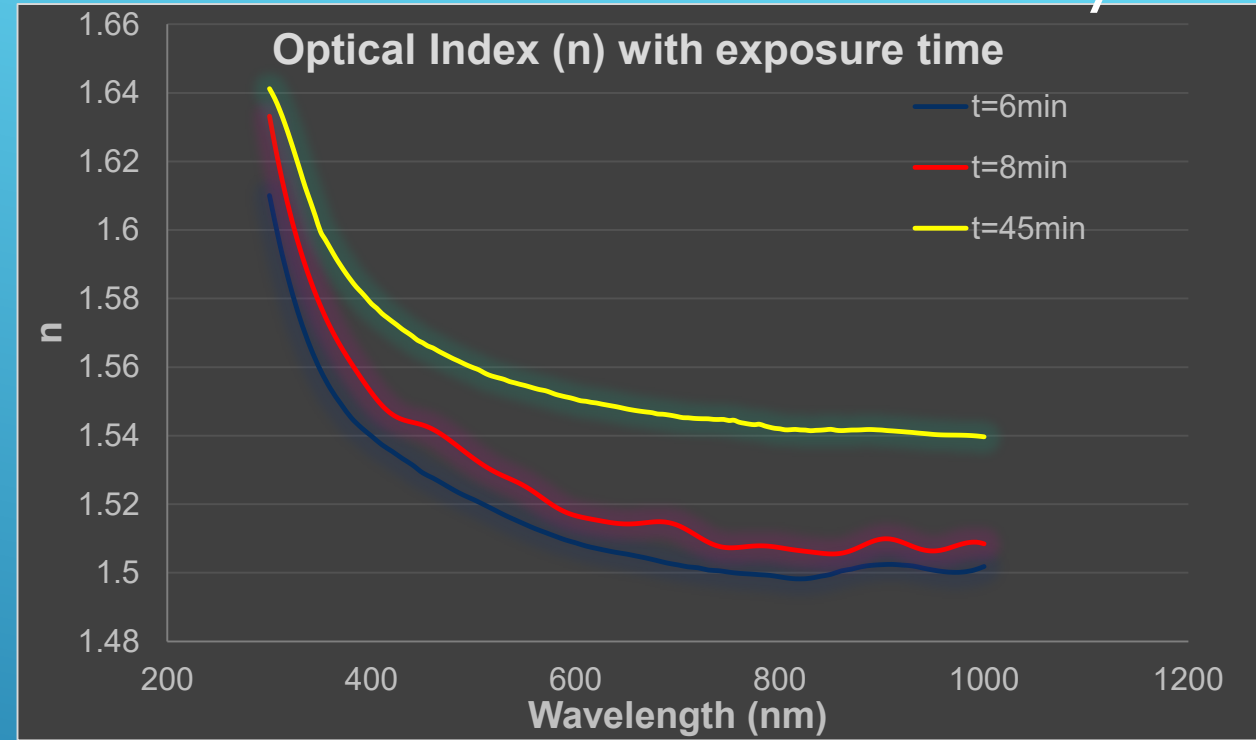
Preliminary Results



Ellipsometer data (ψ , Δ) and fitting



n, k with wavelength (nm)
(exposure time = 45 min)



Conclusion

- As the dosage increases, the index of the resist increases as well.
- The index has an average range of 1.50 – 1.57 (@630nm)

The next step?

Future work aims to create thin film samples that can be exposed directly using the Nanoscribe for more accurate samples.

